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spond to a collection of information unless it displays a valid OMB control number				
	Application Number	10/512,405 🗸		
	Filing Date	June 15, 2005		
	First Named Inventor	Nobumitsu TAKASE		
	Art Unit	2812		
	Examiner Name	Not Yet Assigned		
	Attorney Docket Number	474082002800		

Total Number of Pages in This Submis	sion 21	Attorney Do	cket Number	474082002800			
ENCLOSURES (Check all that apply)							
Fee Transmittal Form	Drawing	(s)		After Allowance Communication to TC			
Fee Attached	Licensin	Licensing-related Papers		Appeal Communication to Board of Appeals and Interferences			
Amendment/Reply	Petition			Appeal Communication to TC (Appeal Notice, Brief, Reply Brief)			
After Final		to Convert to a nal Application		Proprietary Information			
Affidavits/declaration(s)		Attorney, Revocation Correspondence		Status Letter			
Extension of Time Request	Terminal	Terminal Disclaimer		X Other Enclosure(s) (please Identify below):			
Express Abandonment Request	Request for Refund			Return Receipt Post Card Request for Corrected Filing Receipt			
Information Disclosure Statement	CD, Nun	CD, Number of CD(s)		Copy of OFR with corrections in red Request For Correct Notice Of Recordation Of			
Certified Copy of Priority Document(s)		,		Assignment (2 pages) Corrected Recordation Cover Sheet			
	La	ndscape Table on	CD	Copy of NOR w/corrections in red, copy of orig. Recordation Cover Sheet and Assignment and copy of Req. for Corrected OFR Sup. Application Data Sheet			
			į	Sup. Application Data Sheet			
Reply to Missing Parts/ Incomplete Application	Remarks						
Reply to Missing Parts under 37 CFR 1.52 or 1.53							
SIGNATURE OF APPLICANT, ATTORNEY, OR AGENT							
Firm Name MORRISON & FOERSTEP LLP -							
Signature Department of Tallet							
Printed name Kevin R. Spivak	_ (-			
Date January 30, 2006			Reg. No.	43,148			



(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of: Nobumitsu TAKASE et al.

Application No.: 10/512,405

Confirmation No.: 4607

Filed: June 15, 2005

Art Unit: 2812

For: HIGH-RESISTANCE SILICON WAFER AND

ITS MANUFACTURING METHOD

Examiner: Not Yet Assigned

REQUEST FOR CORRECTED FILING RECEIPT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

Applicants hereby request that a corrected Filing Receipt be issued in the aboveidentified patent application. The official Filing Receipt received by Applicants, a copy of which is attached hereto, has an error in the title.

High resistance silicon wafer and method for production thereof should be:

High-resistance silicon wafer and its manufacturing method.

Application No.: 10/512,405 2 Docket No.: 474082002800

Applicants additionally request that all pertinent U.S. Patent and Trademark Office records relating to the subject application be changed to reflect this correction.

Dated: January 30, 2006

Respectfully submitted

Kevin R. Spivak

Registration No.: 43, 48

MORRISON & FOERSTER LLP

1650 Tysons Blvd, Suite 300 McLean, Virginia 22102

(703) 760-7762



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25227

SUITE 300

MCLEAN, VA 22102

FILING OR 371 (c) DATE

ART UNIT

FIL FEE REC'D

ATTY.DOCKET NO

DRAWINGS

TOT CLMS IND CLMS

10/512,405 06/15/2005

MORRISON & FOERSTER LLP 1650 TYSONS BOULEVARD

2812

1594

474082002800

17

CONFIRMATION NO. 4607

FILING RECEIPT

OC000000016356604

Date Mailed: 06/24/2005

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

Nobumitsu Takase, Tokyo, JAPAN; Hideshi Nishikawa, Tokyo, JAPAN; Makoto Ito, Tokyo, JAPAN; Koji Sueoka, Tokyo, JAPAN; Shinsuke Sadamitsu, Tokyo, JAPAN;



Assignment For Published Patent Application

SUMITOMO MITSUBISHI SILICON CORPORATION, Minato-ku, Tokyo, JAPAN

Power of Attorney: The patent practitioners associated with Customer Number 25227.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/04866 04/16/2003

Foreign Applications

JAPAN 2002-127509 04/26/2002 JAPAN 2002-360731 12/12/2002

Projected Publication Date: 09/29/2005

Non-Publication Request: No

Early Publication Request: No

DOCKETED

Title

its manufacturing

. High-resistance silicon wafer and method for production thereof

Preliminary Class

438

PROTECTING YOUR INVENTION OUTSIDE THE UNITED STATES

Since the rights granted by a U.S. patent extend only throughout the territory of the United States and have no effect in a foreign country, an inventor who wishes patent protection in another country must apply for a patent in a specific country or in regional patent offices. Applicants may wish to consider the filing of an international application under the Patent Cooperation Treaty (PCT). An international (PCT) application generally has the same effect as a regular national patent application in each PCT-member country. The PCT process **simplifies** the filing of patent applications on the same invention in member countries, but **does not result** in a grant of "an international patent" and does not eliminate the need of applicants to file additional documents and fees in countries where patent protection is desired.

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The grant of a license does not in any way lessen the responsibility of a licensee for the security of the subject



(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of: Nobumitsu TAKASE et al.

Application No.: 10/512,405

Confirmation No.: 4607

Filed: June 15, 2005

Art Unit: 2812

For: HIGH-RESISTANCE SILICON WAFER AND

METHOD FOR PRODUCTION THEREOF

Examiner: Not Yet Assigned

REQUEST FOR CORRECTED NOTICE OF RECORDATION OF ASSIGNMENT

MS Assignment Recordation Services Director of the US Patent and Trademark Office P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

The Notice of Recordation of Assignment which was recorded on June 15, 2005 at Reel 016819, Frame 0225, has an error in the fourth assignor's name.

SUEOKA, KOUJI should be: SUEOKA, KOJI.

Attached is a copy of the Notice of Recordation of Assignment, a corrected Recordation Cover Sheet, a copy of the originally recorded cover sheet, and a copy of the Assignment. It is respectfully requested that the appropriate correction is made.

We are also attaching a copy of a Request for Corrected Filing Receipt filed concurrently with this request in which the title of the application is to be corrected. It is respectfully requested that the title on the Notice of Recordation also be corrected.

The error of the assignor's name occurred on our part and accordingly the fee of \$40.00 according to 37 CFR § 1.21(h) is due. The Commissioner is authorized to charge the recording fee to **Deposit Account No. 03-1952**, referencing docket no. <u>474082002800</u>.

Dated: January 30, 2006

Respectfully submitted,

Kevin R. Spivak

Registration No.: 43,148 MORRISON & FOERSTER LLP 1650 Tysons Blvd, Suite 300 McLean, Virginia 22102

(703) 760-7762





UNITED STATES PATENT AND TRADEMARK OFFICE

UNDER SECRETARY OF COMMERCE FOR INTELLECTUAL PROPERTY AND DIRECTOR OF THE UNITED STATES PATENT AND TRADEMARK OFFICE

NOVEMBER 28, 2005

PTAS



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KEVIN R. SPIVAK MORRISON & FOERSTER LLP 1650 TYSONS BLVD, SUITE 300 MCLEAN, VA 22102

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THE ENCLOSED DOCUMENT HAS BEEN RECORDED BY THE ASSIGNMENT DIVISION OF THE U.S. PATENT AND TRADEMARK OFFICE. A COMPLETE MICROFILM COPY IS AVAILABLE AT THE ASSIGNMENT SEARCH ROOM ON THE REEL AND FRAME NUMBER REFERENCED BELOW.

PLEASE REVIEW ALL INFORMATION CONTAINED ON THIS NOTICE. THE INFORMATION CONTAINED ON THIS RECORDATION NOTICE REFLECTS THE DATA PRESENT IN THE PATENT AND TRADEMARK ASSIGNMENT SYSTEM. IF YOU SHOULD FIND ANY ERRORS OR HAVE QUESTIONS CONCERNING THIS NOTICE, YOU MAY CONTACT THE EMPLOYEE WHOSE NAME APPEARS ON THIS NOTICE AT 571-272-3350. PLEASE SEND REQUEST FOR CORRECTION TO: U.S. PATENT AND TRADEMARK OFFICE, MAIL STOP: ASSIGNMENT SERVICES DIVISION, P.O. BOX 1450, ALEXANDRIA, VA 22313.

47408 - 200 28.00

RECORDATION DATE: 06/15/2005

REEL/FRAME: 016819/0225 NUMBER OF PAGES: 3

BRIEF: ASSIGNMENT OF ASSIGNOR'S INTEREST (SEE DOCUMENT FOR DETAILS).

ASSIGNOR:

TAKASE, NOBUMITSU

DOC DATE: 06/06/2005

ASSIGNOR:

NISHIKAWA, HIDESHI

DOC DATE: 06/03/2005

ASSIGNOR:

ITO, MAKOTO

DOC DATE: 06/06/2005

ASSIGNOR:

SUEOKA, KOUJI-KOJI

DOC DATE: 06/08/2005

ASSIGNOR:

SADAMITSU, SHINSUKE

DOC DATE: 06/06/2005

KRS/MRH DOCKETED RECEIVED DEC 1 3 2005

MORRISON & FOERSTER LLP

016819/0225 PAGE 2

ASSIGNEE:

SUMITOMO MITSUBISHI SILICON
CORPORATION
2-1, SHIBAURA 1-CHOME, MINATO-KU
TOKYO, JAPAN 105-0023

SERIAL NUMBER: 10512405

FILING DATE: 06/15/2005

PATENT NUMBER: ISSUE DATE:

TITLE: HIGH-RESISTANCE SILICON WAFER AND METHOD FOR PRODUCTION THEREOF

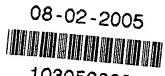
MARY BENTON, EXAMINER ASSIGNMENT DIVISION OFFICE OF PUBLIC RECORDS its Manufacturing (see attacked Capy of Reg. Corrected Feling Receipt) Form PTO-1595 (Rev. 09/04) OMB No. 0651-0027 (exp. 6/30/200)

U.S. DEPARTMENT OF COMMERCE United States Patent and Trademark Office

TION FORM COVER SHEET

PATENTS ONLY To the Director of the U.S. Patent and Trademark Office: Please record the attached documents or the new address(es) below. 1. Name of conveying party(ies)/Execution Date(s): 2. Name and address of receiving party(ies) Nobumitsu TAKASE (06/06/2005), Hideshi NISHIKAWA Name: Sumitomo Mitsubishi Silicon Corporation (06/03/2005), Makoto ITO (06/06/2005), Koji SUEOKA (06/08/2005), and Shinsuke SADAMITSU (06/06/2005) Internal Address: Execution Date(s): June 8, 2005 Street Address: x No Yes Additional name(s) of conveying party(ies) attached? Sumitomo Mitsubishi Silicon Corporation 2-1, Shibaura 1-chome, Minato-ku 3. Nature of Conveyance: Assignment Merger Security Agreement Change of Name Tokyo City:_ Government Interest Assignment State: Executive Order 9424, Confirmatory License Zip: 105-0023 Country: Japan Corrected Recordation Form originally filed Additional name(s) & address(es) Other on June 15, 2005 and recorded at Reel attached: Yes No 016819/Frame 0225 4. Application or patent number(s): This document is being filed together with a new application. A. Patent Application No.(s) B. Patent No.(s) 10/512,405 Additional numbers attached? Yes 5. Name and address to whom correspondence 6. Total number of applications and concerning document should be mailed: patents involved: Kevin R. Spivak **MORRISON & FOERSTER LLP** 40.00 7. Total fee (37 CFR 1.21(h) & 3.41) \$ Internal Address: Atty. Dkt.: 474082002800 Authorized to be charged by credit card Street Address: 1650 Tysons Blvd, Suite 300 х Authorized to be charged to deposit account Enclosed None required (government interest not affecting title) City: McLean 8. Payment Information 22102 a. Credit Card State: Zip: Last 4 Numbers (703) 760-7743 **Expiration Date** Phone Number: (703) 760-7777 03-1952 Fax Number: b. Deposit Account Number Authorized User Name Kevin R. Spivak KSpivak@mofo.com Email Address: 9. Signature: January 30, 2006 Signature Date Kevin R. Spivak - 43,148 Total number of pages including cover sheet, attachments, and documents: Name of Person Signing

Form PTO-1595 (Rev. 09/04)



U.S. DEPARTMENT OF COMMERCE

Date

3

Total number of pages including cover

sheet, attachments, and documents:

OMB No. 0651-0027 (exp. 6/30/2005 United States Patent and Trademark Office FT 103053393 To the Director of the U.S. Patent and Trademark Office: Please record the attached documents or the new address(es) below. Name of conveying party(les)/Execution Date(s): 2. Name and address of receiving party(ies) Nobumitsu TAKASE (06/06/2005), Hideshi NISHIKAWA Name: Sumitomo Mitsubishi Silicon Corporation (06/03/2005), Makoto ITO (08/06/2005), Kouji SUEOKA (06/08/2005), and Shinsuke SADAMITSU (06/06/2005) Internal Address: Execution Date(s): in parentheses after inventor name Street Address: X No Additional name(s) of conveying party(les) attached? Sumitomo Mitsubishi Silicon Corporation 2-1, Shibaura 1-chome, Minato-ku 3. Nature of Conveyance: x Assignment Merger Change of Name Security Agreement City: Government Interest Assignment State: Executive Order 9424, Confirmatory License 105-0023 Country: Japan Additional name(s) & address(es) Other х attached: 4. Application or patent number(s): This document is being filed together with a new application. A. Patent Application No.(s) B. Patent No.(s) 10/512,405 Additional numbers attached? Yes 5. Name and address to whom correspondence 6. Total number of applications and concerning document should be malled: patents involved: Kevin R. Spivak MORRISON & FOERSTER LLP 40.00 7. Total fee (37 CFR 1.21(h) & 3.41) Internal Address/Atty. Dkt.: 474082002800 Authorized to be charged by credit card Street Address: 1650 Tysons Blvd, Suite 300 Authorized to be charged to deposit account 06/20/2005 MKATPAGN 00000052 031/952 10512405 Enclosed 40.00 DA 02 FC:8021 None required (government interest not affecting title) McLean City: 8. Payment Information 22102 State: Zip: a. Credit Card Last 4 Numbers (703) 760-7743 **Expiration Date** Phone Number: (703) 760-7777 03-1952 Fax Number: b. Deposit Account Number Authorized User Name Kevin R. Spivak ∢Spivąk@mofo.oom **Email Address:** 9. Signature June 15, 2005

Kevin R. Spivak - 43,1

Name of Person Signing

MORRISON & FOERSTER LLP

For good and valuable consideration, the receipt and sufficiency of which are hereby acknowledged, the undersigned hereby assign(s), transfer(s) and set(s) over to:

Sumitomo Mitsubishi Silicon Corporation 2-1, Shibaura 1-chome, Minato-ku Tokyo 105-0023 JAPAN

(hereinafter designated as the "ASSIGNEE"), its successors and assigns, the entire right, title, and interest for the United States in the invention, and all applications for patent and any Letters Patent which may be granted therefor, including said application, and all United States Letters Patent which may be granted thereof, and all divisions, reissues, continuations and extensions thereof, the said interest being the entire ownership of said Letters Patent when granted to be held by said ASSIGNEE, its successors, assigns or their legal representatives, to the full end of the term for which said Letters Patent may be granted, as fully and entirely as the same would have been and enjoyed by Assignor(s) if this assignment had not been made, the application being known by the title:

HIGH-RESISTANCE SILICON WAFER AND ITS MANUFACTURING METHOD

Attorney Docket No.: 47408-20028.00

for which the undersigned has/have executed an application for patent in the United States of America on the same day herewith. Where this instrument is not filed concurrently with the application, the following identifying information may be added after execution:

Serial No.: 10/512,405 Filing Date: October 25, 2004

The undersigned hereby agree(s) to sign and execute any further
documents and instruments which may be necessary, lawful and proper in
the prosecution of said above-named application or in the preparation and
prosecution of any continuing, continuation-in-part, substitute, divisional,
renewal, reexamination or reissue application or in any amendments,
extension of interference proceedings, or otherwise to secure the title
thereto to the ASSIGNEE.

- 2. The undersigned agree(s) to execute all papers and documents and perform any act which may be necessary in connection with claims or provisions of the International Convention for Protection of Industrial Property of similar agreements.
- 3. The undersigned agree(s) to perform all affirmative acts which may be necessary to obtain a grant of a valid United States patent to the ASSIGNEE.
- 4. The undersigned hereby authorize(s) and request(s) the Commissioner of Patents in the United States to issue any and all Letters Patent resulting from said application or any division or divisions or continuing applications thereof to the said ASSIGNEE.
- 5. The undersigned hereby grant(s) to the firm of Morrison & Foerster LLP the power to insert on this assignment any further identification which may be necessary or desirable in order to comply with the rules of the United States Patent and Trademark Office for recordation of this document.

IN WITNESS WHEREBY, executed by the undersigned on the date(s) opposite the undersigned name(s).

06/06/2005	Nobenters Tapases
Date	Typed Name: Nobumitsu TAKASE
06/03/2005	Holeshi hishi kawa
Date	Typed Name: Hideshi NISHIKAWA
06/06/2005	maketa Ita
Date	Typed Name: Makoto ITO
06/08/2005	Koji Sueoka
Date	Typed Name: Koji SUEOKA
06/06 /2005	Shinsuke Sadamitsu
Date	Typed Name: Shinguke SADAMITSU



(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of: Nobumitsu TAKASE et al.

Application No.: 10/512,405

12,405 Confirmation No.: 4607

Filed: June 15, 2005

Art Unit: 2812

For: HIGH-RESISTANCE SILICON WAFER AND

ITS MANUFACTURING METHOD

Examiner: Not Yet Assigned

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Dated: January 30, 2006

Kevin R. Spivak

Registration No.: 43, 48

MORRISON & FOERSTER LLP 1650 Tysons Blvd, Suite 300

McLean, Virginia 22102

(703) 760-7762

PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Offices
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FILING OR 37 (c) DATE

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ATTY.DOCKET NO

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IND CLMS

10/512,405 16/15/2005

2812

474082002800

17

25227 MORRISON & FOERSTER LLP 1650 TYSONS BOULEVARD **SUITE 300** MCLEAN, VA 22102

CONFIRMATION NO. 4607 FILING RECEIPT

OC000000016356604

Date Mailed: 06/24/2005

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Applicant(s)

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Assignment For Published Patent Application

SUMITOMO MITSUBISHI SILICON CORPORATION, Minato-ku, Tokyo, JAPAN

Power of Attorney: The patent practitioners associated with Customer Number 25227.

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GRANTED

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